L Number	Hits	Search Text	DB	Time stamp
1	1620	"dual damascene" and etch\$3	USPAT;	2002/07/19 09:40
			US-PGPUB;	
			EPO; JPO	
6	110	("dual damascene" and etch\$3) and "etch	USPAT;	2002/07/19 09:40
1		mask"	US-PGPUB;	
			EPO; JPO	
11	103		USPAT;	2002/07/19 09:42
		mask") and (vias via trenches trench)	US-PGPUB;	
			EPO; JPO	
16	101		USPAT;	2002/07/19 09:42
		mask") and (vias via trenches trench)) and	US-PGPUB;	
		pattern\$3	EPO; JPO	
21	39		USPAT;	2002/07/19 09:49
		mask") and (vias via trenches trench)) and	US-PGPUB;	1
		pattern\$3) and "low k"	EPO; JPO	
26	1511	convert\$3 near6 dielectric	USPAT;	2002/07/19 09:54
			US-PGPUB;	
			EPO; JPO	
31	452	(convert\$3 near6 dielectric) and etch\$	USPAT;	2002/07/19 09:55
			US-PGPUB;	
			EPO; JPO	2000/07/10 00 55
36	59	1 1 1	USPAT;	2002/07/19 09:55
		and ("etch mask" "etch stop")	US-PGPUB;	
			EPO; JPO	